# SYNLETT Spotlight 308

This feature focuses on a reagent chosen by a postgraduate, highlighting the uses and preparation of the reagent in current research

## Trimethylsilyl Chloride (TMSCl)

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### Introduction

Trimethylsilyl chloride is a valuable reagent in organic synthesis. It is a colorless liquid with a boiling point of 57-58 °C, easy to hydrolyse, unstable towards air, and has a pungent odor. It is commercially available and has been

widely used in organic synthesis as chloridizing and activating reagents. Further it is used as protecting group and to accelerate and improve yields, stereospecificity, and regioselectivity for organic reactions. Herein, the applications of TMSCl in the recent five years are listed and reviewed.

#### Abstracts



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TMS

NH

TMSCI

aq HCI

75-90% yield

MeCN, reflux

>99% de

NHAc Q

ί Β<sup>1</sup> Ο

(E) Thiols and disulfides could be directly converted into the corresponding sulfonyl chlorides in the presence of chlorotrimethylsilane nitrate salts in excellent yields through oxidative chlorination. Sulfides and sulfoxides were also found to undergo oxidation to sulfones under similar conditions.<sup>5</sup>

RSH TMSCI, MNO<sub>3</sub> CH<sub>2</sub>Cl<sub>2</sub>, 50 °C RS–SR

TMSC

MeCN-DMF

сно

сно

ĊHO

+ MeCONH<sub>2</sub>

СНО.

(F) A new multicomponent reaction of *ortho*-phthaldehyde, aldehydes, and N-alkyl/aryl substituted ureas was developed in the presence of TMSCI. A series of novel 3-substituted isoindolinones were prepared for the first time in moderate yields with a diastereomeric excess of >99%.<sup>6</sup>

(G) A Mannich-type three-component reaction involving aldehydes, acetamide, and enolizable ketones or  $\beta$ -keto esters in the presence of TMSCl afforded  $\beta$ -acetamido carbonyl compounds with high diastereoselectivity.<sup>7</sup>

(H) A range of allylic alk-3(2)-enoates in the presence of DBU (1,8-diazabicycl[5.4.0]undec-7-ene) and an excess amount of TMSCl under reflux in acetonitrile underwent an Ireland–Claisen [3,3] rearrangement to yield 2-ethylidene  $\gamma$ , $\delta$ -unsaturated carboxylic acids and 2-butenylidene  $\gamma$ , $\delta$ -unsaturated carboxylic acids with high yields.<sup>8</sup>

(I) Barnes et al. reported a facile and mild method for the synthesis of MOM-protected carbamates (MOM = methoxymethyl) in the presence of chlorotrimethylsilane, avoiding the use of carcinogen MOM–Cl. A variety of functionalities, including Boc, sulfonamide, and acetamide protecting groups are tolerant to this reaction.<sup>9</sup>

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 $R^1 = Ar$ , Alk;  $R^2 = Bn$ , Me, *t*-Bu;  $R^3 = Me$ , Et, Bn

DABCO

TMSCI-DBU

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